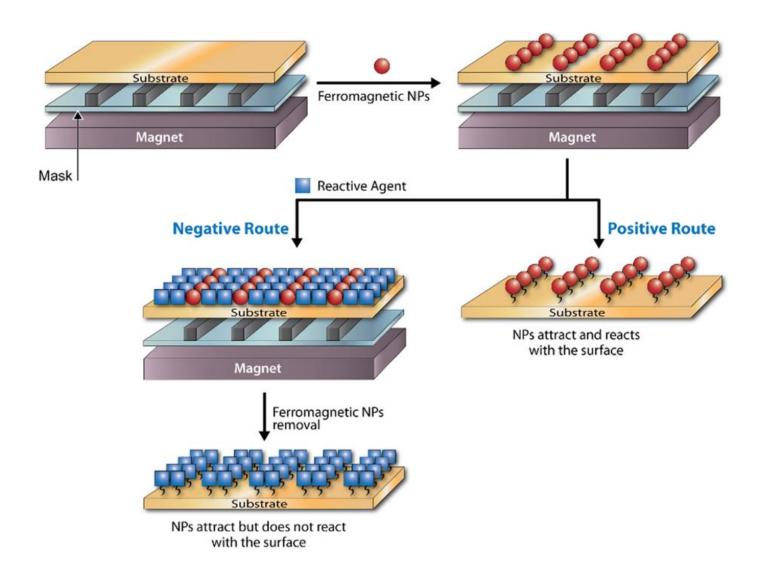
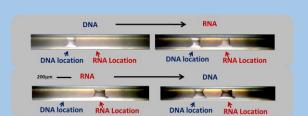
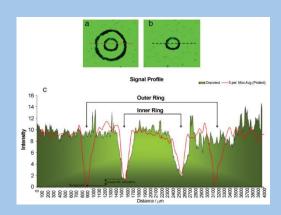
Magneto-Lithography (ML) Method

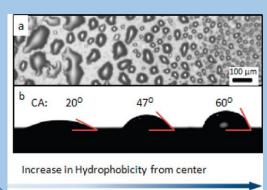
Scheme of two approaches using positive and negative ML



Magnetolithography (ML) Applications







Tube modified by Urease using negative ML

Part indicato

H₂N NH₂ + H₂O Trease

CO₂ + 2NH₃
pH 1

Oltra Sensitive of molecules and

Molecular and Multi

stage patterning

Non flat surfaces patterning Micro reactors



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positive and negative NNL
positive and negative NNL
positive and negative NNL

2½m Mask

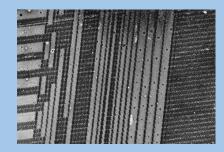
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Jum Atterlitt off

Patterning using hard disc as a mask



Patterning Bradient Properties

Dynamic mask

